## **Amendments to the Claims**:

The following listing of claims will replace all prior versions, and listings, of claims in the application:

1. (Original) A ferroelectric film including a perovskite ferroelectric or a bismuth layer-structured ferroelectric shown by ABO<sub>3</sub> or  $(Bi_2O_2)^{2+}(A_{m-1}B_mO_{3m+1})^{2-}$  (wherein A represents at least one ion selected from the group consisting of Li<sup>+</sup>, Na<sup>+</sup>, K<sup>+</sup>, Pb<sup>2+</sup>, Ca<sup>2+</sup>, Sr<sup>2+</sup>, Ba<sup>2+</sup>, Bi<sup>3+</sup> and La<sup>3+</sup>, B represents at least one ion selected from the group consisting of Fe<sup>3+</sup>, Ti<sup>4+</sup>, Zr<sup>4+</sup>, Nb<sup>5+</sup>, Ta<sup>5+</sup>, W<sup>6+</sup> and Mo<sup>6+</sup>, and m is a natural number),

wherein at least four-fold coordinated Si<sup>4+</sup> or Ge<sup>4+</sup> is included in the A site ion.

2. (Original) A ferroelectric film including a perovskite ferroelectric or a bismuth layer-structured ferroelectric shown by ABO<sub>3</sub> or  $(Bi_2O_2)^{2+}(A_{m-1}B_mO_{3m+1})^{2-}$  (wherein A represents at least one ion selected from the group consisting of Li<sup>+</sup>, Na<sup>+</sup>, K<sup>+</sup>, Pb<sup>2+</sup>, Ca<sup>2+</sup>, Sr<sup>2+</sup>, Ba<sup>2+</sup>, Bi<sup>3+</sup> and La<sup>3+</sup>, B represents at least one ion selected from the group consisting of Fe<sup>3+</sup>, Ti<sup>4+</sup>, Zr<sup>4+</sup>, Nb<sup>5+</sup>, Ta<sup>5+</sup>, W<sup>6+</sup> and Mo<sup>6+</sup>, and m is a natural number),

wherein at least four-fold coordinated Si<sup>4+</sup> or Ge<sup>4+</sup> is included in the A site ion; and wherein the ferroelectric film is a solid solution with a dielectric shown by X<sub>2</sub>SiO<sub>5</sub>, X<sub>4</sub>Si<sub>3</sub>O<sub>12</sub>, X<sub>2</sub>GeO<sub>5</sub> or X<sub>4</sub>Ge<sub>3</sub>O<sub>12</sub> (wherein X represents Bi<sup>3+</sup>, Fe<sup>3+</sup>, Sc<sup>3+</sup>, Y<sup>3+</sup>, La<sup>3+</sup>, Ce<sup>3+</sup>, Pr<sup>3+</sup>, Nd<sup>3+</sup>, Pm<sup>3+</sup>, Sm<sup>3+</sup>, Eu<sup>3+</sup>, Gd<sup>3+</sup>, Tb<sup>3+</sup>, Dy<sup>3+</sup>, Ho<sup>3+</sup>, Er<sup>3+</sup>, Tm<sup>3+</sup>, Yb<sup>3+</sup> or Lu<sup>3+</sup>).

3. (Currently Amended) A ferroelectric film including a perovskite ferroelectric or a bismuth layer-structured ferroelectric shown by ABO<sub>3</sub> or  $(Bi_2O_2)^{2+}(A_{m-1}B_mO_{3m+1})^{2-}$  (wherein A represents at least one ion selected from the group consisting of Li<sup>+</sup>, Na<sup>+</sup>, K<sup>+</sup>, Pb<sup>2+</sup>, Ca<sup>2+</sup>, Sr<sup>2+</sup>, Ba<sup>2+</sup>, Bi<sup>3+</sup> and La<sup>3+</sup>, B represents at least one ion selected from the group consisting of Fe<sup>3+</sup>, Ti<sup>4+</sup>, Zr<sup>4+</sup>, Nb<sup>5+</sup>, Ta<sup>5+</sup>, W<sup>6+</sup> and Mo<sup>6+</sup>, and m is a natural number),

wherein at least four-fold coordinated Si<sup>4+</sup> or Ge<sup>4+</sup> is included in the A site ion; and

wherein the ferroelectric film includes at least one transition element in an amount of 5 to 40 mol% in total, the transition element having the <u>a</u> maximum positive valence which is +1 or more greater than the <u>a</u> valence of the A site ion of the ABO<sub>3</sub> or  $(Bi_2O_2)^{2+}(A_{m-1}B_mO_{3m+1})^{2-}$ .

4. (Currently Amended) A ferroelectric film including a perovskite ferroelectric or a bismuth layer-structured ferroelectric shown by ABO<sub>3</sub> or  $(Bi_2O_2)^{2+}(A_{m-1}B_mO_{3m+1})^{2-}$  (wherein A represents at least one ion selected from the group consisting of Li<sup>+</sup>, Na<sup>+</sup>, K<sup>+</sup>, Pb<sup>2+</sup>, Ca<sup>2+</sup>, Sr<sup>2+</sup>, Ba<sup>2+</sup>, Bi<sup>3+</sup> and La<sup>3+</sup>, B represents at least one ion selected from the group consisting of Fe<sup>3+</sup>, Ti<sup>4+</sup>, Zr<sup>4+</sup>, Nb<sup>5+</sup>, Ta<sup>5+</sup>, W<sup>6+</sup> and Mo<sup>6+</sup>, and m is a natural number),

wherein at least four-fold coordinated Si<sup>4+</sup> or Ge<sup>4+</sup> is included in the A site ion; and wherein the ferroelectric film includes at least one transition element in an amount of 5 to 40 mol% in total, the transition element having the a maximum positive valence which is +1 or more greater than the a valence of the B site ion of the ABO<sub>3</sub> or (Bi<sub>2</sub>O<sub>2</sub>)<sup>2+</sup>(A<sub>m-1</sub>B<sub>m</sub>O<sub>3m+1</sub>)<sup>2-</sup>.

5. (Currently Amended) A ferroelectric film including a perovskite ferroelectric or a bismuth layer-structured ferroelectric shown by ABO<sub>3</sub> or  $(Bi_2O_2)^{2+}(A_{m-1}B_mO_{3m+1})^{2-}$  (wherein A represents at least one ion selected from the group consisting of Li<sup>+</sup>, Na<sup>+</sup>, K<sup>+</sup>, Pb<sup>2+</sup>, Ca<sup>2+</sup>, Sr<sup>2+</sup>, Ba<sup>2+</sup>, Bi<sup>3+</sup> and La<sup>3+</sup>, B represents at least one ion selected from the group consisting of Fe<sup>3+</sup>, Ti<sup>4+</sup>, Zr<sup>4+</sup>, Nb<sup>5+</sup>, Ta<sup>5+</sup>, W<sup>6+</sup> and Mo<sup>6+</sup>, and m is a natural number),

wherein at least four-fold coordinated  $\mathrm{Si}^{4+}$  or  $\mathrm{Ge}^{4+}$  is included in the A site ion; wherein the ferroelectric film includes at least one transition element having the a maximum positive valence which is +1 or more greater than the a valence of the B site ion of the ABO<sub>3</sub> or  $(\mathrm{Bi}_2\mathrm{O}_2)^{2+}(\mathrm{A}_{m-1}\mathrm{B}_m\mathrm{O}_{3m+1})^{2-}$ ;

wherein the ferroelectric film includes at least one transition element having the  $\underline{a}$  maximum positive valence which is +1 or more greater than the  $\underline{a}$  valence of the A site ion of the ABO<sub>3</sub> or  $(Bi_2O_2)^{2+}(A_{m-1}B_mO_{3m+1})^{2-}$ ; and

wherein the transition elements are included in an amount of 5 to 40 mol% in the A and B sites in total.

6. (Currently Amended) A ferroelectric film including a perovskite ferroelectric or a bismuth layer-structured ferroelectric shown by ABO<sub>3</sub> or (Bi<sub>2</sub>O<sub>2</sub>)<sup>2+</sup>(A<sub>m-1</sub>B<sub>m</sub>O<sub>3m+1</sub>)<sup>2-</sup> (wherein A represents at least one ion selected from the group consisting of Li<sup>+</sup>, Na<sup>+</sup>, K<sup>+</sup>, Pb<sup>2+</sup>, Ca<sup>2+</sup>, Sr<sup>2+</sup>, Ba<sup>2+</sup>, Bi<sup>3+</sup> and La<sup>3+</sup>, B represents at least one ion selected from the group consisting of Fe<sup>3+</sup>, Ti<sup>4+</sup>, Zr<sup>4+</sup>, Nb<sup>5+</sup>, Ta<sup>5+</sup>, W<sup>6+</sup> and Mo<sup>6+</sup>, and m is a natural number),

wherein the ferroelectric film is a solid solution with a dielectric shown by  $X_2SiO_5$ ,  $X_4Si_3O_{12}$ ,  $X_2GeO_5$  or  $X_4Ge_3O_{12}$  (wherein X represents  $Bi^{3+}$ ,  $Fe^{3+}$ ,  $Sc^{3+}$ ,  $Y^{3+}$ ,  $La^{3+}$ ,  $Ce^{3+}$ ,  $Pr^{3+}$ ,  $Nd^{3+}$ ,  $Pm^{3+}$ ,  $Sm^{3+}$ ,  $Eu^{3+}$ ,  $Gd^{3+}$ ,  $Tb^{3+}$ ,  $Dy^{3+}$ ,  $Ho^{3+}$ ,  $Er^{3+}$ ,  $Tm^{3+}$ ,  $Yb^{3+}$  or  $Lu^{3+}$ ); and

wherein at least four-fold coordinated Si<sup>4+</sup> or Ge<sup>4+</sup> is included in the A site ion;

wherein the ferroelectric film includes at least one transition element in an amount of 5 to 40 mol% in total, the transition element having the <u>a</u> maximum positive valence which is +1 or more greater than the <u>a</u> valence of the A site ion of the ABO<sub>3</sub> or  $(Bi_2O_2)^{2+}(A_{m-1}B_mO_{3m+1})^{2-}$ .

7. (Currently Amended) A ferroelectric film including a perovskite ferroelectric or a bismuth layer-structured ferroelectric shown by ABO<sub>3</sub> or (Bi<sub>2</sub>O<sub>2</sub>)<sup>2+</sup>(A<sub>m-1</sub>B<sub>m</sub>O<sub>3m+1</sub>)<sup>2-</sup> (wherein A represents at least one ion selected from the group consisting of Li<sup>+</sup>, Na<sup>+</sup>, K<sup>+</sup>, Pb<sup>2+</sup>, Ca<sup>2+</sup>, Sr<sup>2+</sup>, Ba<sup>2+</sup>, Bi<sup>3+</sup> and La<sup>3+</sup>, B represents at least one ion selected from the group consisting of Fe<sup>3+</sup>, Ti<sup>4+</sup>, Zr<sup>4+</sup>, Nb<sup>5+</sup>, Ta<sup>5+</sup>, W<sup>6+</sup> and Mo<sup>6+</sup>, and m is a natural number), wherein at least four-fold coordinated Si<sup>4+</sup> or Ge<sup>4+</sup> is included in the A site ion;

wherein the ferroelectric film is a solid solution with a dielectric shown by  $X_2SiO_5$ ,  $X_4Si_3O_{12}$ ,  $X_2GeO_5$  or  $X_4Ge_3O_{12}$  (wherein X represents  $Bi^{3+}$ ,  $Fe^{3+}$ ,  $Sc^{3+}$ ,  $Y^{3+}$ ,  $La^{3+}$ ,  $Ce^{3+}$ ,  $Pr^{3+}$ ,  $Nd^{3+}$ ,  $Pm^{3+}$ ,  $Sm^{3+}$ ,  $Eu^{3+}$ ,  $Gd^{3+}$ ,  $Tb^{3+}$ ,  $Dy^{3+}$ ,  $Ho^{3+}$ ,  $Er^{3+}$ ,  $Tm^{3+}$ ,  $Yb^{3+}$  or  $Lu^{3+}$ ); and

wherein the ferroelectric film includes at least one transition element in an amount of 5 to 40 mol% in total, the transition element having the <u>a</u> maximum positive valence which is +1 or more greater than the <u>a</u> valence of the B site ion of the ABO<sub>3</sub> or  $(Bi_2O_2)^{2+}$   $(A_{m-1}B_mO_{3m+1})^{2-}$ .

8. (Currently Amended) A ferroelectric film including a perovskite ferroelectric or a bismuth layer-structured ferroelectric shown by ABO<sub>3</sub> or  $(Bi_2O_2)^{2+}(A_{m-1}B_mO_{3m+1})^{2-}$  (wherein A represents at least one ion selected from the group consisting of Li<sup>+</sup>, Na<sup>+</sup>, K<sup>+</sup>, Pb<sup>2+</sup>, Ca<sup>2+</sup>, Sr<sup>2+</sup>, Ba<sup>2+</sup>, Bi<sup>3+</sup> and La<sup>3+</sup>, B represents at least one ion selected from the group consisting of Fe<sup>3+</sup>, Ti<sup>4+</sup>, Zr<sup>4+</sup>, Nb<sup>5+</sup>, Ta<sup>5+</sup>, W<sup>6+</sup> and Mo<sup>6+</sup>, and m is a natural number),

wherein the ferroelectric film is a solid solution with a dielectric shown by  $X_2SiO_5$ ,  $X_4Si_3O_{12}$ ,  $X_2GeO_5$  or  $X_4Ge_3O_{12}$  (wherein X represents  $Bi^{3+}$ ,  $Fe^{3+}$ ,  $Sc^{3+}$ ,  $Y^{3+}$ ,  $La^{3+}$ ,  $Ce^{3+}$ ,  $Pr^{3+}$ ,  $Nd^{3+}$ ,  $Pm^{3+}$ ,  $Sm^{3+}$ ,  $Eu^{3+}$ ,  $Gd^{3+}$ ,  $Tb^{3+}$ ,  $Dy^{3+}$ ,  $Ho^{3+}$ ,  $Er^{3+}$ ,  $Tm^{3+}$ ,  $Yb^{3+}$  or  $Lu^{3+}$ );

wherein at least four-fold coordinated Si<sup>4+</sup> or Ge<sup>4+</sup> is included in the A site ion:

wherein the ferroelectric film includes at least one transition element having the  $\underline{a}$  maximum positive valence which is +1 or more greater than the  $\underline{a}$  valence of the B site ion of the ABO<sub>3</sub> or  $(Bi_2O_2)^{2+}(A_{m-1}B_mO_{3m+1})^{2-}$ ;

wherein the ferroelectric film includes at least one transition element having the  $\underline{a}$  maximum positive valence which is +1 or more greater than the  $\underline{a}$  valence of the A site ion of the ABO<sub>3</sub> or  $(Bi_2O_2)^{2+}(A_{m-1}B_mO_{3m+1})^{2-}$ ; and

wherein the transition elements are included in an amount of 5 to 40 mol% in the A and B sites in total.

9. (Currently Amended) The ferroelectric film as defined in any of claims 1 to 8, wherein the ferroelectric film includes Pb(Zr, Ti)O<sub>3</sub> which includes at least four-fold coordinated Si<sup>4+</sup> or Ge<sup>4+</sup> in the A site ion in an amount of 1%1 mol% or more; and

wherein at least one transition element having the a maximum positive valence of +3 or more is included in the A site in an amount of 5 to 40 mol% in total.

10. (Currently Amended) The ferroelectric film as defined in any of claims 1 to 8, wherein the ferroelectric film includes Pb(Zr, Ti)O<sub>3</sub> which includes at least four-fold coordinated Si<sup>4+</sup> or Ge<sup>4+</sup> in the A site ion in an amount of 1%1 mol% or more; and

wherein at least one transition element having the a maximum positive valence of +5 or more is included in the B site in an amount of 5 to 40 mol% in total.

11. (Currently Amended) A ferroelectric film including Pb(Zr, Ti)O<sub>3</sub> which includes at least four-fold coordinated Si<sup>4+</sup> or Ge<sup>4+</sup> in the <u>a</u>Pb site ion in an amount of 1%1 mol% or more,

wherein at least one transition element having the a maximum positive valence of +3 or more is included in the Pb site;

wherein at least one transition element having the a maximum positive valence of +5 or more is included in the a Zr or Ti site; and

wherein the transition elements are included in an mount of 5 to 40 mol% in the Pb and Zr or Ti sites in total.

12. (Currently Amended) A ferroelectric film including Pb(Zr, Ti)O<sub>3</sub> which includes at least four-fold coordinated Si<sup>4+</sup> or Ge<sup>4+</sup> in the a Pb site ion in an amount of 1%1 mol% or more,

wherein at least one of La and other lanthanoid series ions is included in the Pb site in an amount of 5 to 40 mol% in total.

13. (Currently Amended) A ferroelectric film including Pb(Zr, Ti)O<sub>3</sub> which includes at least four-fold coordinated Si<sup>4+</sup> or Ge<sup>4+</sup> in the <u>a</u>Pb site ion in an amount of 1%1 mol% or more,

wherein at least one of Nb, V and W is included in the <u>a</u>Zr or Ti site in an amount of 5 to 40 mol% in total.

14. (Currently Amended) A ferroelectric film including Pb(Zr, Ti)O<sub>3</sub> which includes at least four-fold coordinated Si<sup>4+</sup> or Ge<sup>4+</sup> in the <u>a</u>Pb site ion in an amount of 1%1 mol% or more,

wherein at least one of La and other lanthanoid series ions is included in the Pb site, and at least one of Nb, V and W is included in the a Zr or Ti site, in an amount of 5 to 40 mol% in the Pb and Zr or Ti sites in total.

15. (Currently Amended) The ferroelectric film as defined in any of elaim-claims11 to 14, further including:

at least one of Nb, V and W in the Zr or Ti site in an amount twice the amount of of a

Pb ion vacancy in the Pb site.

- 16. (Currently Amended) The ferroelectric film as defined in any of claims 11 to 14 is included including (111)-oriented tetragonal crystals.
- 17. (Currently Amended) The ferroelectric film as defined in any of claims 11 to 14 is included including (001)-oriented rhombohedral crystals.

18-29. (Canceled)

- 30. (Currently Amended) A ferroelectric memory comprising the ferroelectric film as defined in claim-any of claims 1-8, 11-14 and 23-24.1-8 and 11-14.
- 31. (Currently Amended) A piezoelectric device comprising the ferroelectric film as defined in elaim-any of claims 1-8, 11-14 and 23-24.1-8 and 11-14.